

K. Memory (Design & Process Technology) 분과

Room B

창의관 (110)

일 시 : 2월 17일(금) 11:20-12:35

세션명 : [FB2-K] Phase Change Memories

좌 장 : 조성익(전북대학교)

FB2-K-1 11:20-11:50 [Invited] Critical Consideration and Requirements of Access Device for Scalable Phase Change Memory

저자: 박해찬, 박남균, 김석기, 김명섭, 이세호, 최강식, 이정훈,
홍성주

소속: 하이닉스반도체 선행소자A팀

FB2-K-2 11:50-12:05 PCRAM Flip-flop Circuit with Sequential Sleep-in Control Scheme

저자: Jun-Myung Choi, Chul-Moon Jung, and Kyeong-Sik Min
소속: School of Electrical Engineering, Kookmin University

FB2-K-3 12:05-12:20 The Effect of Carbon Incorporated into $In_3Sb_1Te_2$ on Phase Change Characteristics in Phase Change Memory

저자: 김현수^{1,4}, 김용태², 김용인³, 성만영⁴

소속: ¹삼성전자 Memory 사업부, ²한국과학기술연구원, ³KAIST,
⁴고려대학교

FB2-K-4 12:20-12:35 Improved Switching Uniformity in $Ge_2Sb_2Te_5$ based Resistive Switching Memory Device by using Internal Resistor

저자: Jiyong Woo¹, Seungjae Jung¹, Jubong Park¹, Seonghyun Kim¹,
Wootae Lee¹, Dasesoek Lee¹, Euijun Cha², and Hyunsang
Hwang^{1,2}

소속: ¹School of Materials Science and Engineering, Gwangju
Institute of Science and Technology, ²Department of Nanobio
Materials and Electronics, Gwangju Institute of Science and
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